Archive



Burn-in & Test Strategies Workshop

www.bitsworkshop.org

September 6-7, 2017

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SiP Test & Contact Technology

New universal multi-beam Kelvin contactor concept for turret applications

Mathias Westenhuber Johann Pötzinger COHU ITS



BiTS China Workshop Shanghai September 7, 2017





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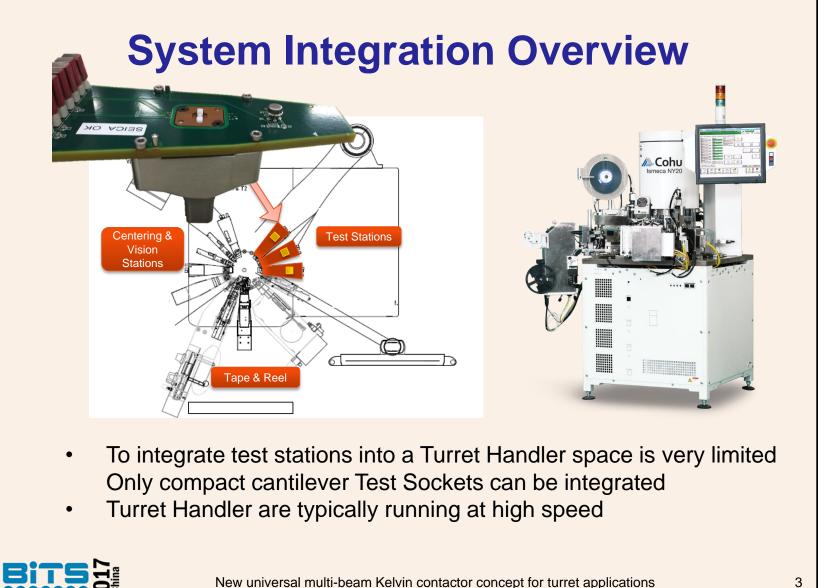
Agenda

- System Integration Overview
- Why multi-beam Kelvin Contactor?
- Validation
- Why side-by-side Kelvin?
- Upside-down load board configuration
- Conclusion



Session 2 Presentation 4

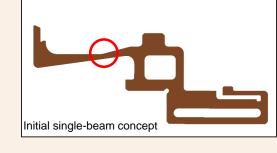
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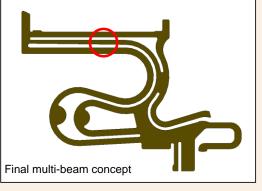


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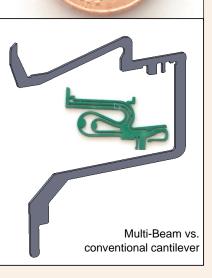
Why Multi-Beam Kelvin Contactor?







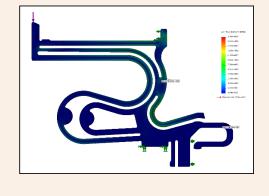
- Significant pin size reduction by maintaining high current carrying capability and good signal integrity
- The multi-beam concept allows to increase the current carrying capacity CCC from 2 A to 3 A
- The cross section was increased from 0.22 mm to 0.55 mm → x2.5!
- Low contact force of 0.20 N (0.20 mm deflection) by maintaining a big cross section





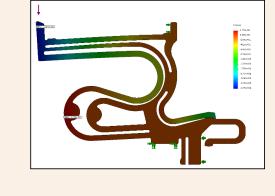
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Lifetime, Stress & Compression Simulation





- The multi-beam concept allows to distribute the stress over the three beams and assures a low mechanical stress in the pin structure
- Mechanical validations did confirm no broken pins up to 10 million cycles

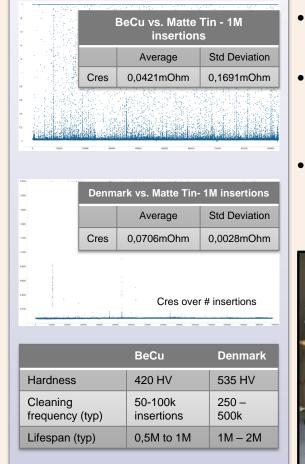


- Compression simulation
 - The multi-beam concept allows a high compression while maintain a low contact force (0.20mm – 0.2N)



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CRES Validation



- Actual lead frame material was used to simulate "Test Floor environment"
- Denmark has significant higher hardness HV vs CuBe and shows a very tight CRES standard deviation
 - Pin material prevents solder transfer and migration which results in longer cleaning intervals and improved pin lifetime

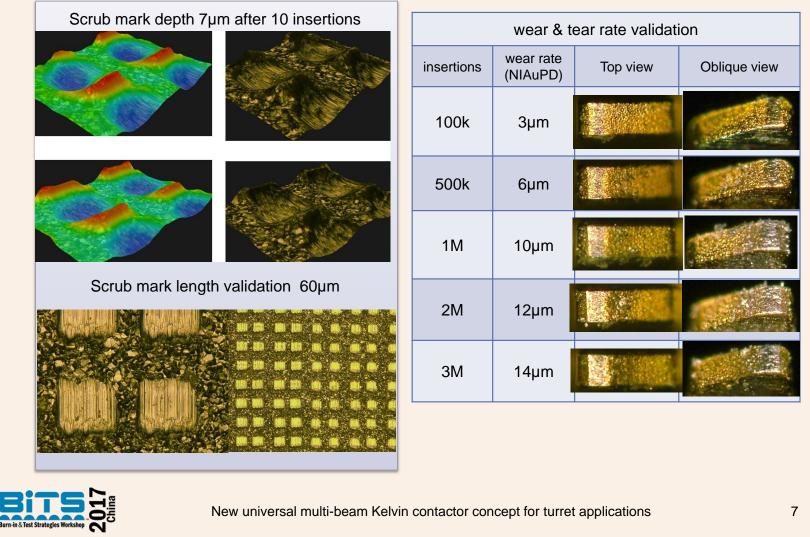




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Validation



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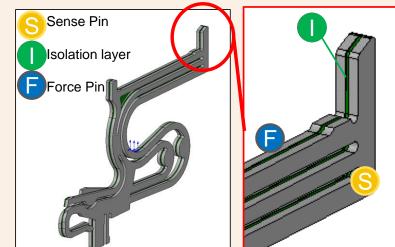
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QFN, DFN, LGA

Side-by-side Architecture





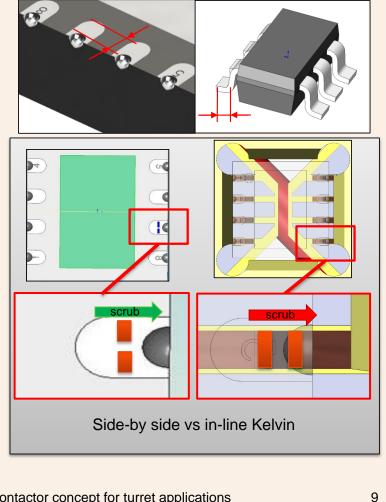
- Force & Sense pin are able to move independently
- High performance insulation layer extremely durable and flexible
- Isolation layer is attached to the force pin
- Total pin thickness ~0.25 mm
- Pin compression creates a 60 μm scrub on the device pad / lead
- Multi-beam structure allows passive cooling for power applications



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Why Side-by-side Kelvin Contactor?

- QFN Devices show a trend towards shorter pad lenghts
- Solderbility Inspection features reducing the available contact area further
- The lead length of small SOT Devices provide insufficient contact area
- Typical contact surface areas are < 0.25mm x 0.2mm
- Low CRES requirements demand a homogenous pin with a defined scrub of 60µm





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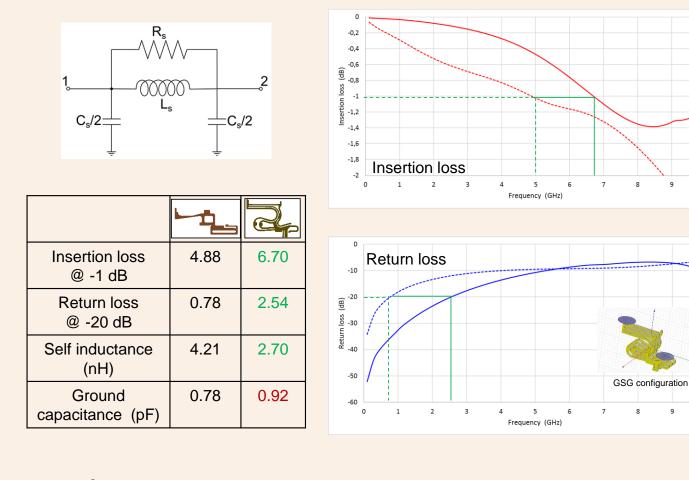
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single-beam

multi-beam

single-beam multi-beam





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New universal multi-beam Kelvin contactor concept for turret applications

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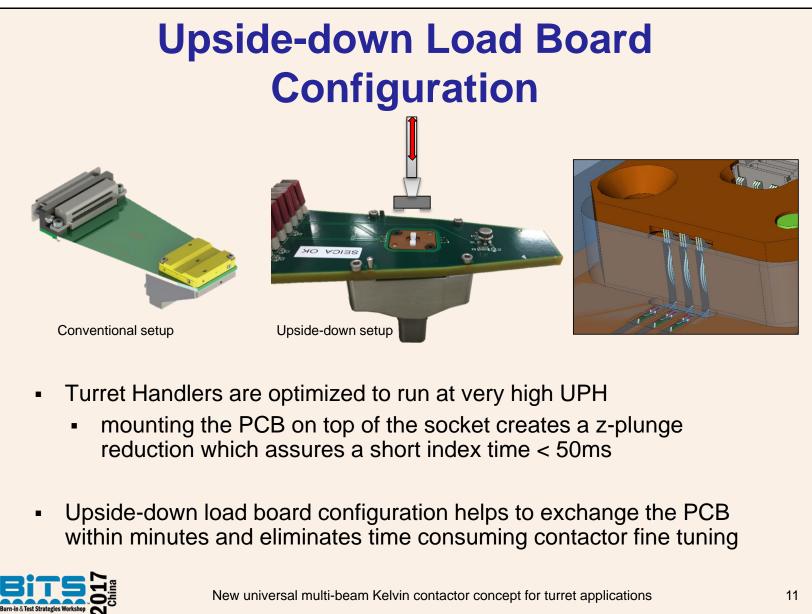
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Conclusion

- New multi-beam released to the marked and confirmed favorable performance multiple customers
- Outstanding lifetime and ease of use have significantly reduced cost of test and increased the efficiency of the test cell
- Multi-beam concept does have the potential to be applied for RF and Power final test and wafer level applications



New universal multi-beam Kelvin contactor concept for turret applications

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